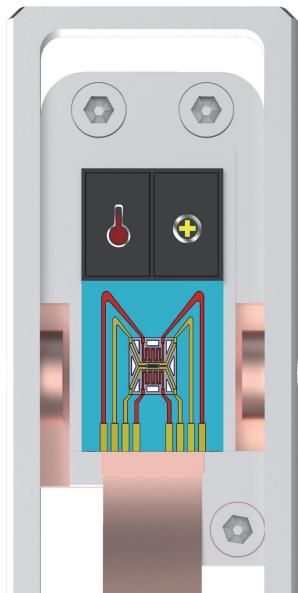




In-situ Atomic-scale Heating-Biasing Coupling System



INSTEMS – TE pro Heating & Biasing

Double-tilt

- α tilting up to $\pm 25^\circ$ *
- β tilting up to $\pm 20^\circ$ *

Multiple external field conditions

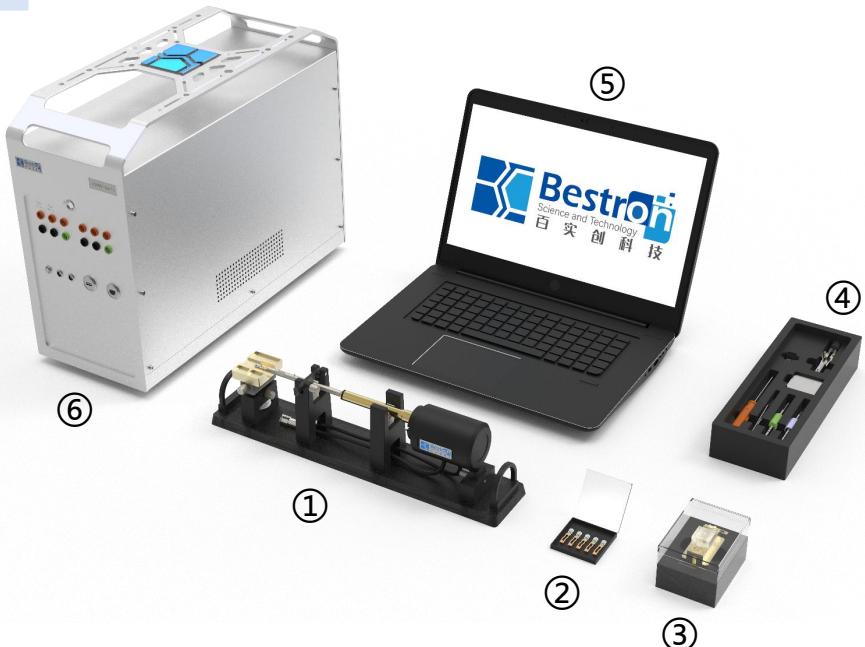
- Heating field
- Biasing field
- Coupled field of heating and biasing

Outstanding thermal and electrical application and measurement

- Wide temperature range (RT - 800°C)
- Ultra high heating precision ($\pm 0.1^\circ\text{C}$ *)
- Programmable heating
- Versatile biasing procedures
- pA-level measurement

COMPONENTS

- ① Double-tilt holder
- ② Mini Labs
- ③ Mini Lab Transfer box
- ④ Tool kit
- ⑤ PC, Software
- ⑥ Control Unit



Note: The specifications listed in * depend on the TEM and the type of Mini lab.



SPECIFICATIONS

Heating	Temperature range	RT - 800°C
	Heating precision	± 0.1°C*
	Temperature measurement	Four-electrode method
	EDS	√
Biasing	Max output voltage	± 50 V *
	Current range	0 – 60 mA*
Double-tilt	Alpha (α) tilt	± 25° *
	Beta (β) tilt	± 20° *
	Accuracy	< 0.1°
Imaging	Spatial resolution	≤ 0.1 nm *
External field	Heating, Biasing, Coupled heating & biasing	

ABOUT US

百实创(北京)科技有限公司

Bestron (Beijing) Science and Technology Co., LTD.

Address: Beijing University of Technology Science park,
Building 29, Yard 1, Jinghai Fifth Road, Tongzhou District,
Beijing, China

Tel:00-86-010-67866979

E-mail: info@bestronst.com

<http://www.bestronst.com>



Wechat



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